STUDIES OF COBALT NANOCONSTRICTIONS BY SCANNING TRANSMISSION X-RAY MICROSCOPY AND MICROMAGNETIC SIMULATIONS

A. Fernández-Pacheco^{2,3*}, <u>A. Szkudlarek</u>^{1*}, L.E. Serrano-Ramón², T. Tyliszczak⁴, Cz. Kapusta¹, M.R. Ibarra³, and J.M. De Teresa^{2,3}

¹AGH University of Science and Technology, Faculty of Physics and Applied Computer Science,

Department of Solid State Physics, Adama Mickiewicza 30, 30–059 Krakow, Poland

²Instituto de Ciencia de Materiales de Aragón (ICMA), Departamento de Física de la Materia

Condensada, Universidad de Zaragoza-CSIC, Pedro Cerbuna 12, 5009 Zaragoza, Spain

³Laboratorio de Microscopías Avanzadas (LMA), Instituto de Nanociencia de Aragón (INA), Universidad

de Zaragoza, Mariano Esquillor 50018 Zaragoza, Spain

⁴Advanced Light Source, Lawrence Berkeley National Laboratory, 1 Cyclotron Road Berkeley, CA, USA

Keywords: magnetic nanoconstriction, Scanning Transmission X-Ray Microscopy (STXM),

 $micromagnetic\ simulations$

**e-mail*: af457@cam.uk.co

High magnetoresistance values reported in literature have attracted a lot of attention to nanomagnetic contacts. However, the physical phenomena which are ruled mainly by the magnetization in the regions adjacent to the nanocostriction [1], might be masked by artifacts [2]. In order to investigate the character of magnetization reversal process the structures with asymmetric contact shape were

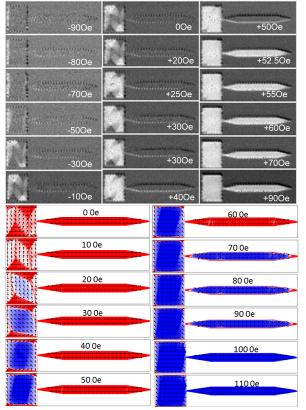


Figure 1: Room temperature STXM images of the structure as a function of the external magnetic field compared with micromagnetic simulations. Values of the *x*-component of the field are shown.

fabricated. The samples consist of a 4 μ m × 4 μ m square pad and a 8 μ m × 1 μ m rectangular wire, which are joined together by a constriction. The minimum size of the contact areas studied is 80×10 nm². The structures were fabricated by focused-electron-beam-induced deposition (FEBID) — a novel single step lithography technique, which allows to obtain high purity polycrystalline cobalt deposit using the Co₂(CO)₈ precursor.

The magnetization reversal was investigated by Scanning Transmission X-ray Microscopy (STXM) at the Advance Light Source in Berkeley. The advanced magnetic imaging by X-Ray Circular Dichroism allows to obtain a unique insight into the process with a spatial resolution of about 40 nm. The analysis of images explains well the experimentally observed magnetoresistance (MR), basing on the theory of anisotropic (AMR) in the diffusive electrical transport regime, i.e. derived from the *y*-component of the magnetization. The micromagnetic simulations, complementary to MR and STXM measurements, correspond very well to the STMX images.

STXM images show a different magnetization structure during reversal as a function of the electrode thickness and constriction size, which is also confirmed by micromagnetic simulations.

The measured MR values are compared with those obtained from simulations.

References

- G. Sarau, C.M. Schneider, J. Appl. Phys. 102 (2007) 083907.
- [2] B. Doudin and M. Viret, J. Phys.: Condens. Matter 20 (2008) 083201.
- [3] A. Fernández-Pacheco *et al.*, *Nanotechnology* 23 (2012) 105703.